Enantioselective Surface Interactions, and CISS Effect



Funded by the European Union Mampi Biswas¹, Alexandre Mamontov¹, Massimiliano Remigio^{1,2}, Kunal Mali², Steven De Feyter², Yves H. Geerts¹ ¹Université Libre de Bruxelles (ULB), Chimie des Polymères CP 206/01, Campus de la Plaine, 1050 Bruxelles, Belgium ²KU Leuven, Division of Molecular Imaging and Photonics, Department of Chemistry, Celestijnenlaan 200F, 3001 Leuven, Belgium

> R (-): ee = 97.19% S (+): ee = 99.42%

Contact: mampi.biswas@ulb.be

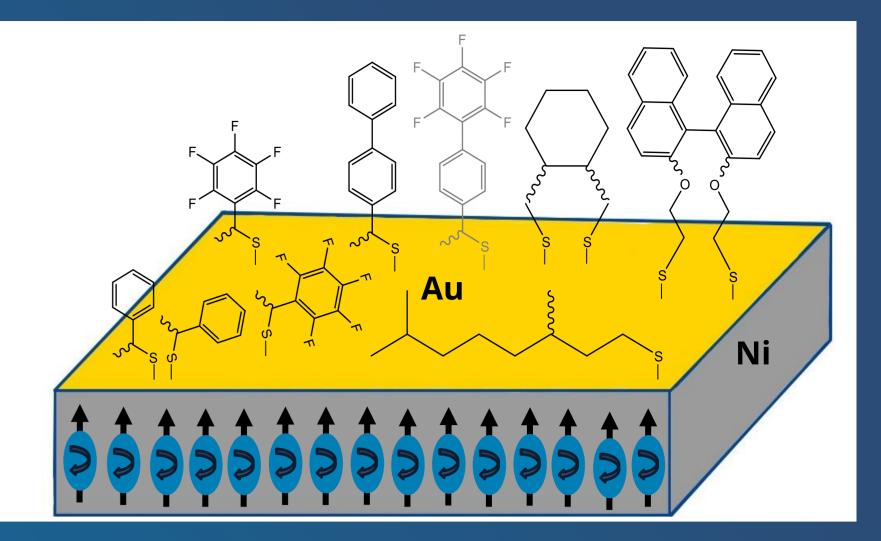
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Introduction

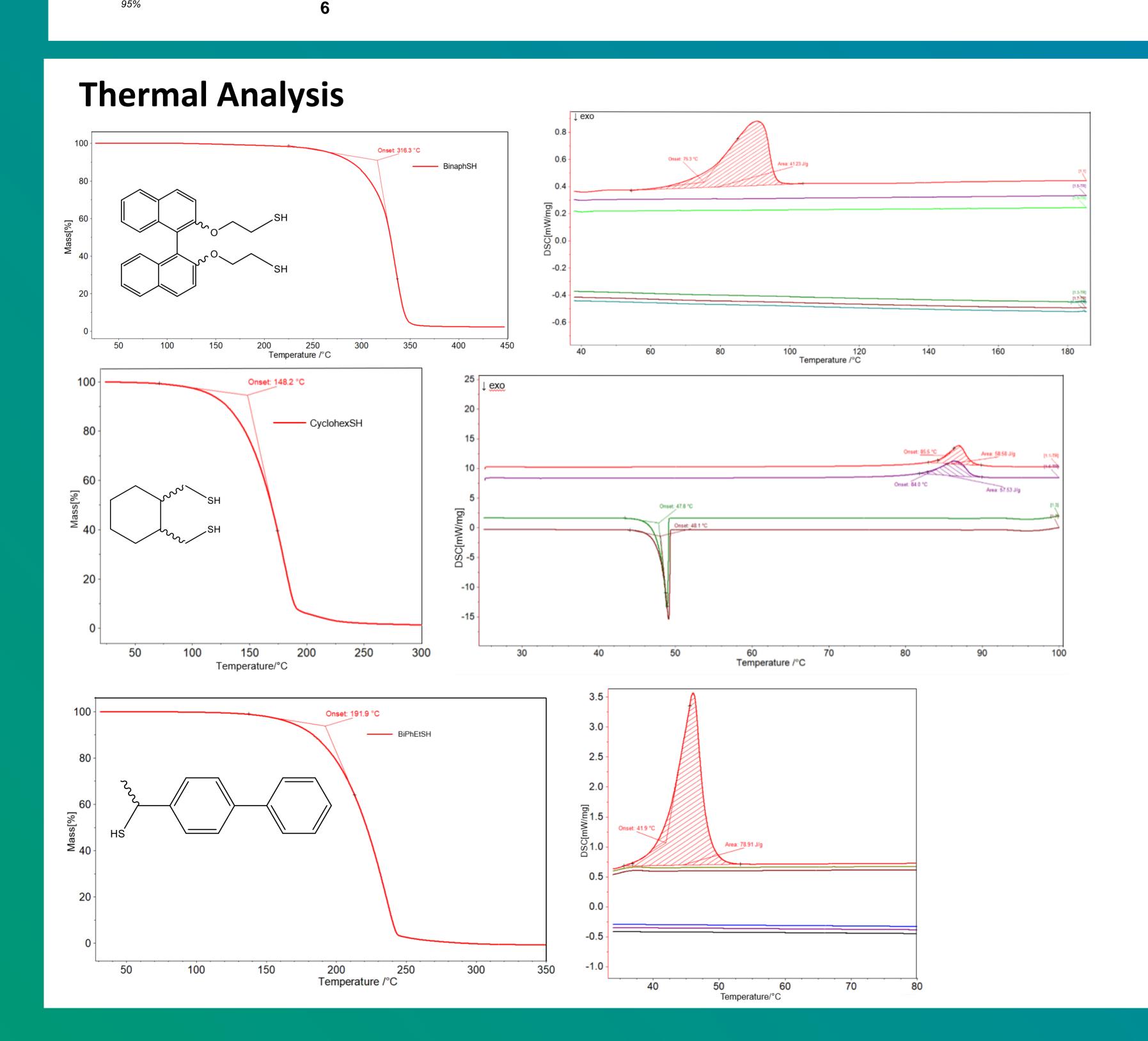
MeOH, inert atm

0 C - r.t., 1.5 d

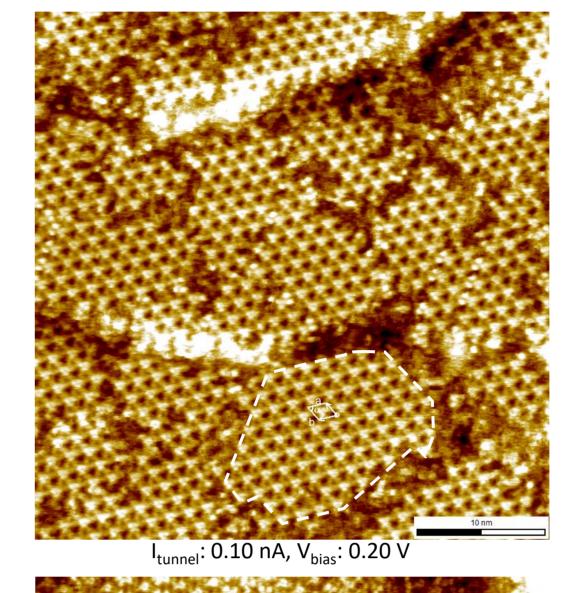
Chirality, a fundamental property of molecules, plays a significant role in their interaction with spin-polarized surfaces. The Chiral Induced Spin Selectivity (CISS) effect links the handedness of chiral molecules to their spin-polarization, resulting in spin-dependent enantioselective adsorption^[1] on spin-polarized surfaces. Our study focuses on how molecular dipole moments, chemical environments, and stereoisomeric configurations impact the CISS effect. We synthesized thiol-functionalized chiral molecules with high enantiomeric purity and the enantiomeric excess, ee > 97% is measured by High-performance liquid chromatography (HPLC) to examine their enantioselective adsorption on Au-Ni surface using scanning tunneling microscopy (STM), atomic force microscopy (AFM) and electrochemical quartz crystal microbalance (EQCM).^[2,3] Understanding these spin-selective behaviors aids in designing self-assembled monolayers (SAMs) for organic field-effect transistors (OFETs),^[4] pharmaceutical and industrial applications and selective surface interactions.

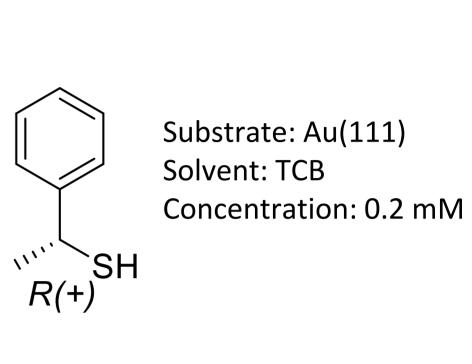


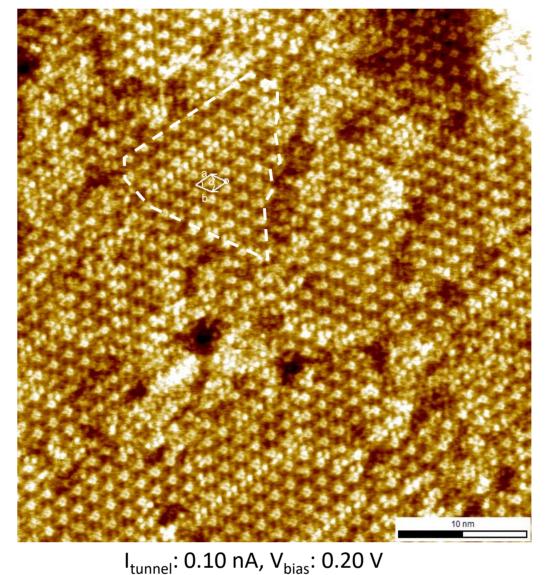
Synthesis r.t. 3h MsCl, Et₃N, CH₂Cl₂ MeOH/H₂O 0 °C - r.t., 2h Acetone 75% 1. DIAD, PPh₃ dry THF, inert atm K_2CO_3 0 °C - r.t., 4 h MeOH/ H2O 2. Hexane, 30 min (Inversion of absolute configuration) R (+): ee = 99.25% 1. DIAD, PPh₃ dry THF, inert atm 0 °C - r.t., overnight MeOH 0 °C - r.t., 1.5 d 2. Hexane, 2 h (Inversion of absolute configuration) R (+): ee = 98.02% 6. 1. DIAD, PPh₃ dry THF, inert atm [PdCl₂(CH₃CN)₂], Na₂CO 0 °C - r.t., 4 h 45 °C, H₂O, Overnight 85% (Inversion of absolute configuration)

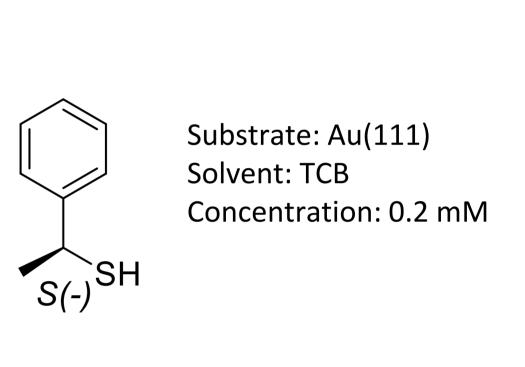


STM Measurements



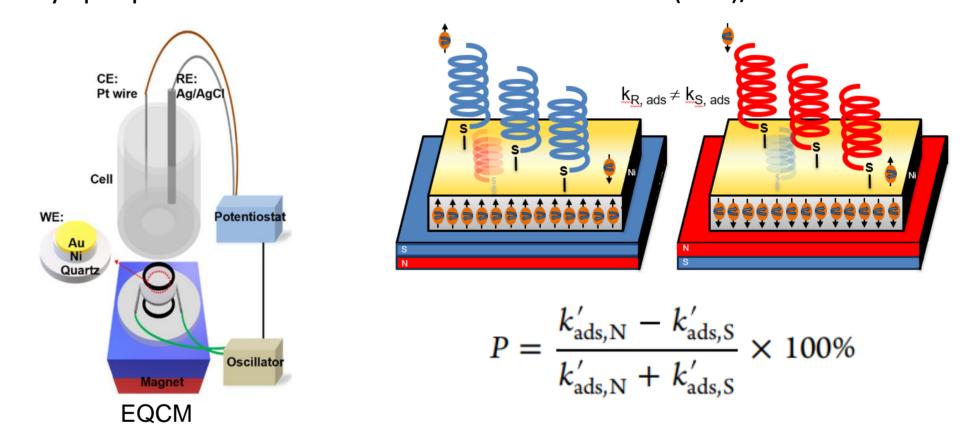






Future Plan

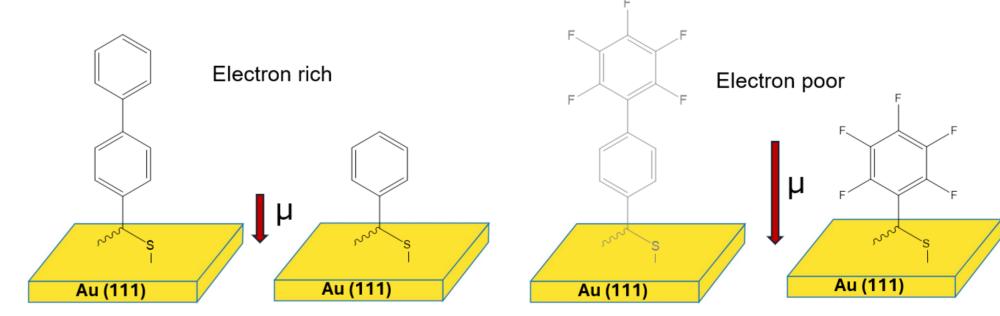
☐ Study spin polarization of R and S enantiomer on Au (111)/Ni surface.



☐ Work function measurements depend on the surface dipole, which arises from both the intrinsic dipole of the molecules in the SAM layer (ΔV_{SAM}) and the dipole formed when the thiol anchoring groups bind to the gold surface (BD).

$$\Delta \Phi = \Delta V_{\rm SAM} + {\rm BD}$$

- ☐ SAM-modified Au surfaces as the source and drain electrodes in an OFET:
- a. Electrode work function
- b. Surface energy of the modified electrodes
- c. Tunnelling resistance of the SAM



Pushback or Pillow Effect

- \square Synthesis of 2`,3`,4`,5`,6`-Pentafluoro- α -methyl[1,1`-biphenyl]-4-methanethiol.
- ☐ Further experiments will be performed to measure the CISS effect and investigate enantioselective adsorption on spin polarized ferromagnetic surface in different chiral molecules.

Conclusion

- ☐ We have synthesized, fully characterized, and purified various chiral compounds to study the structure-property relationship in relation to the CISS effect.
- ☐ Purity and thermal stability of the enantiopure compounds has been checked by HPLC, TGA and DSC measurements.
- ☐ Preliminary adsorption studies Au (111) have been conducted on both enantiomers of 1-Phenyethanethiol.

References and Acknowledgements

[1] Phys. Chem. Chem. Phys., 2020,22, 21570-21582. [2] J.Phys.Chem. Lett., 2021,12,7854–7858. [3] J. Phys. Chem. C, 2023, 127, 14155-14162. [4] J. Mater. Chem. C, 2015, 3, 3007-3015.

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